

Tests on a 6827W13 LGAD



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LGAD 6827w13 02 features

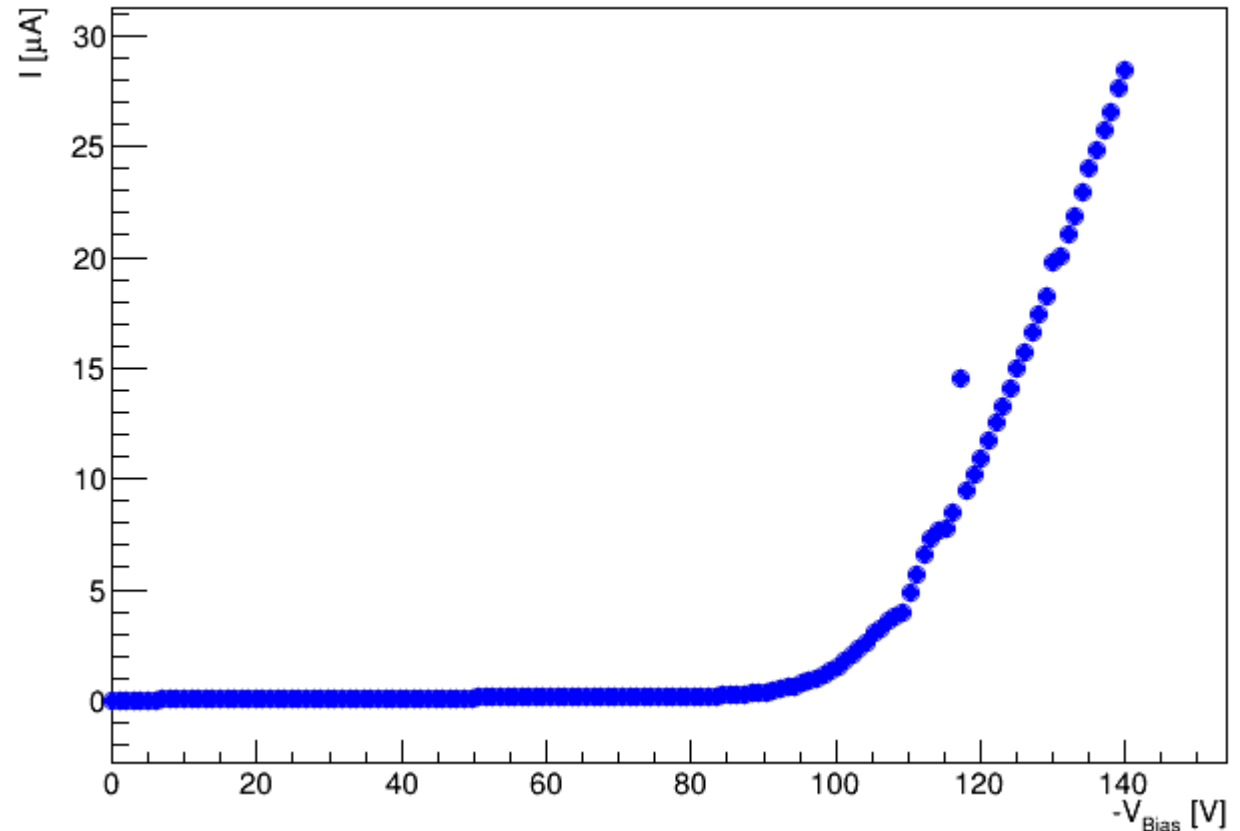
300 μm thick FE-I3 sensor

Standard diffusion time of dopant

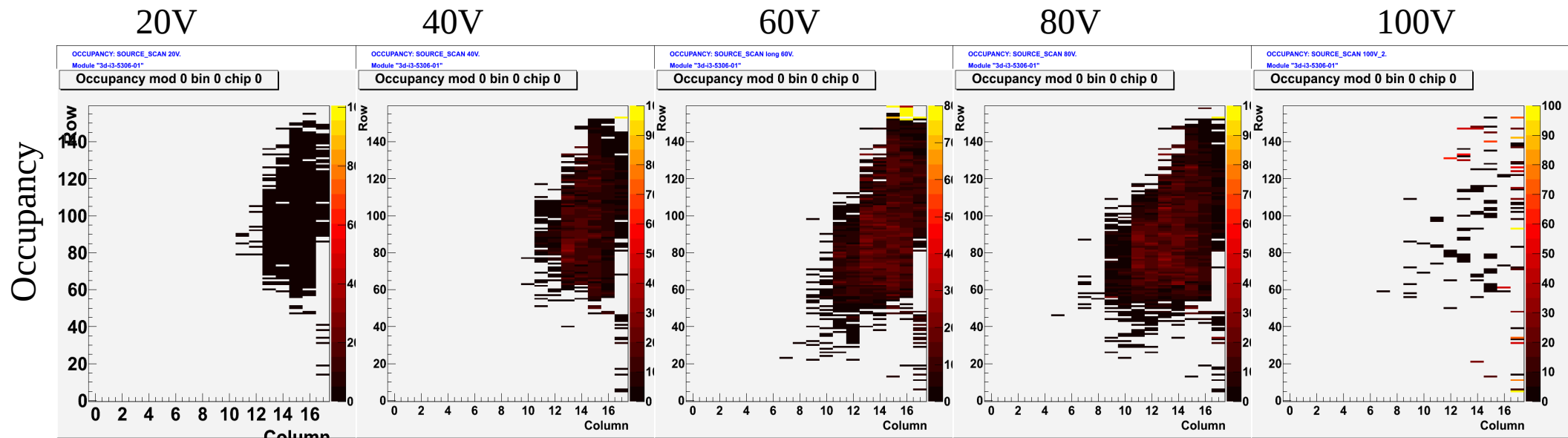
Indium Bonding by Selex

$V_{\text{bd}} \sim -100\text{V}$

IV curve



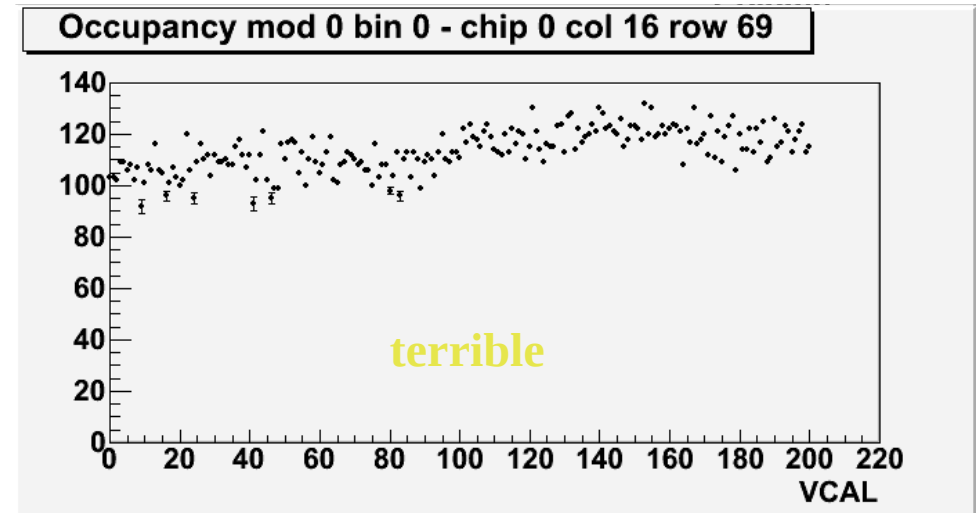
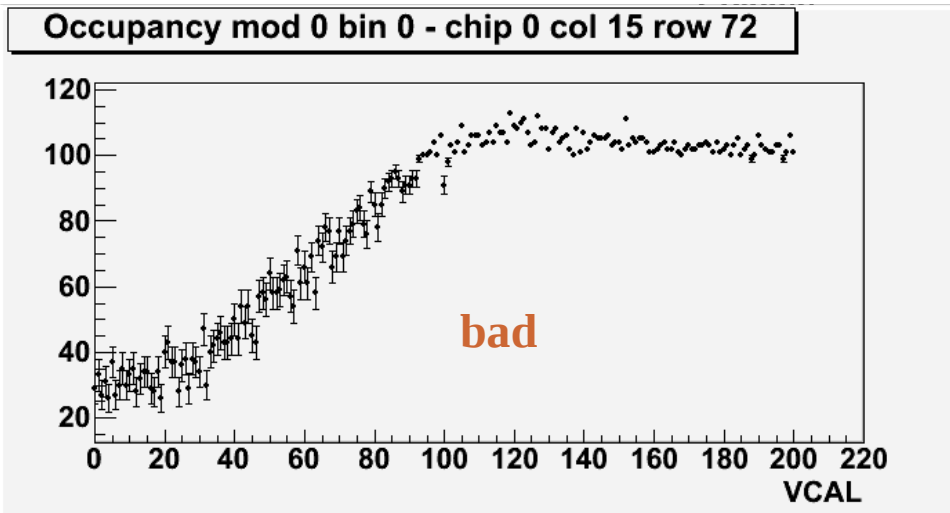
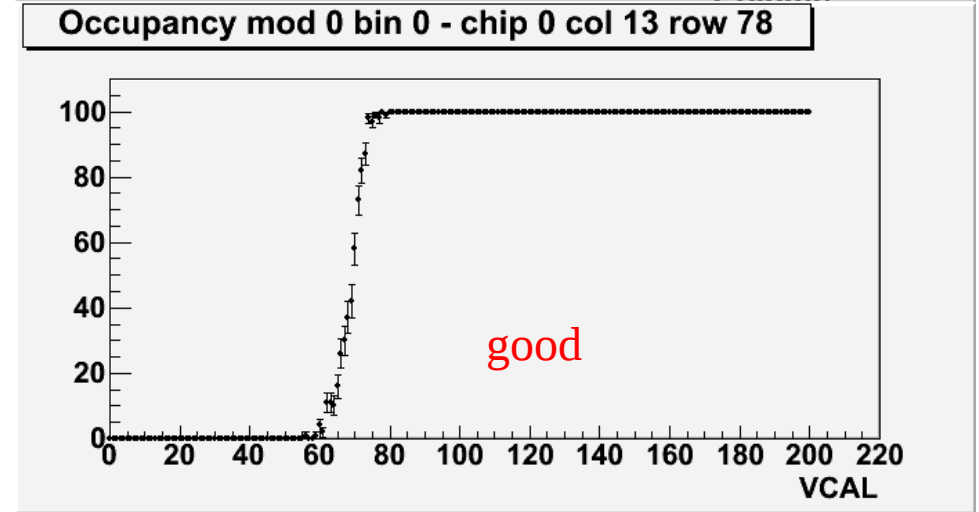
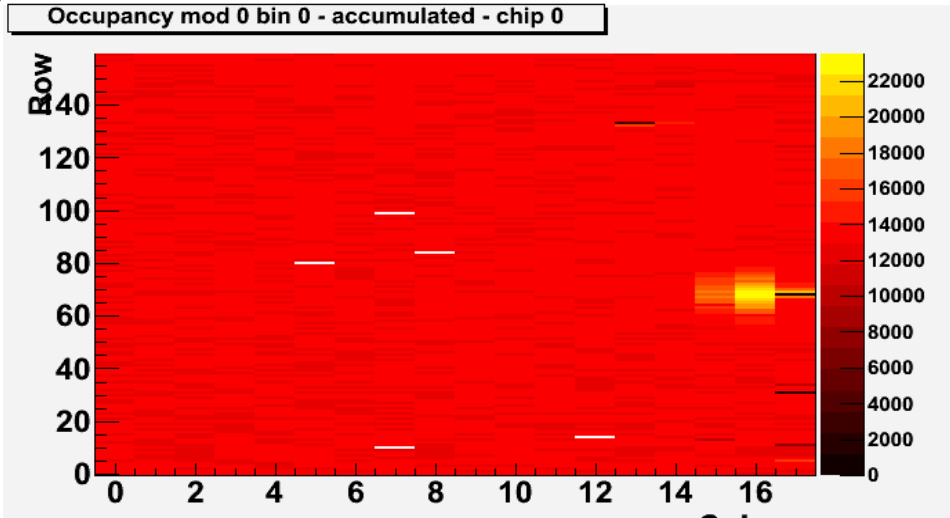
Source Scan vs Bias Voltage



- The **Indium bonding** did not work properly, only a **small region** is connected to the FE
- Sensitive area seems to **increase with voltage** up to 80V around breakdown
- Some **noisy pixels** appear after voltage rump up

Threshold Scan @ -100 V

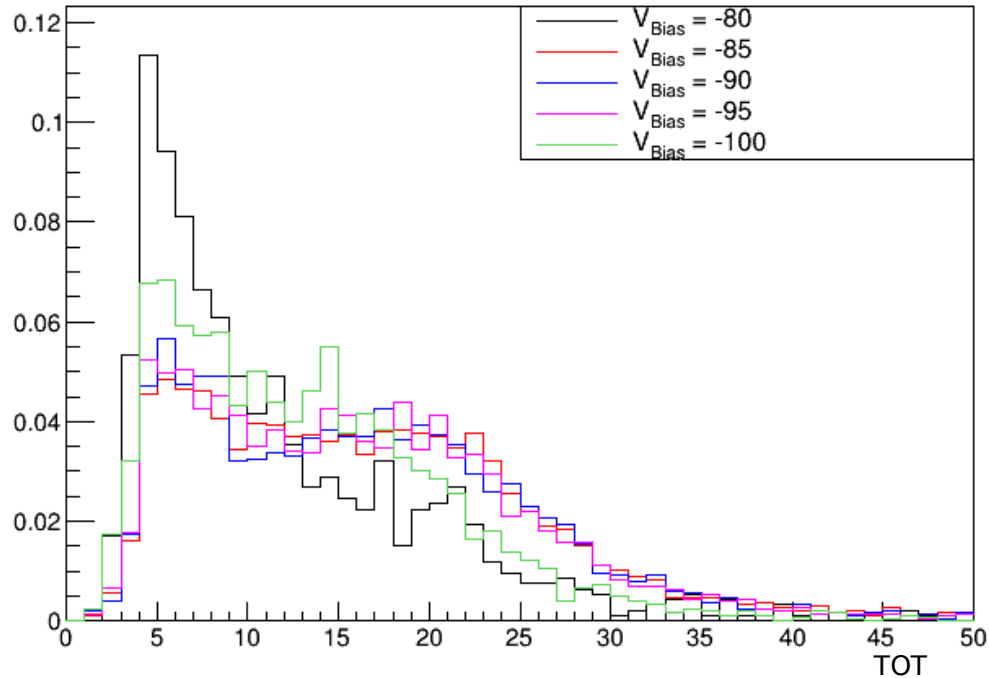
Some S-curves example



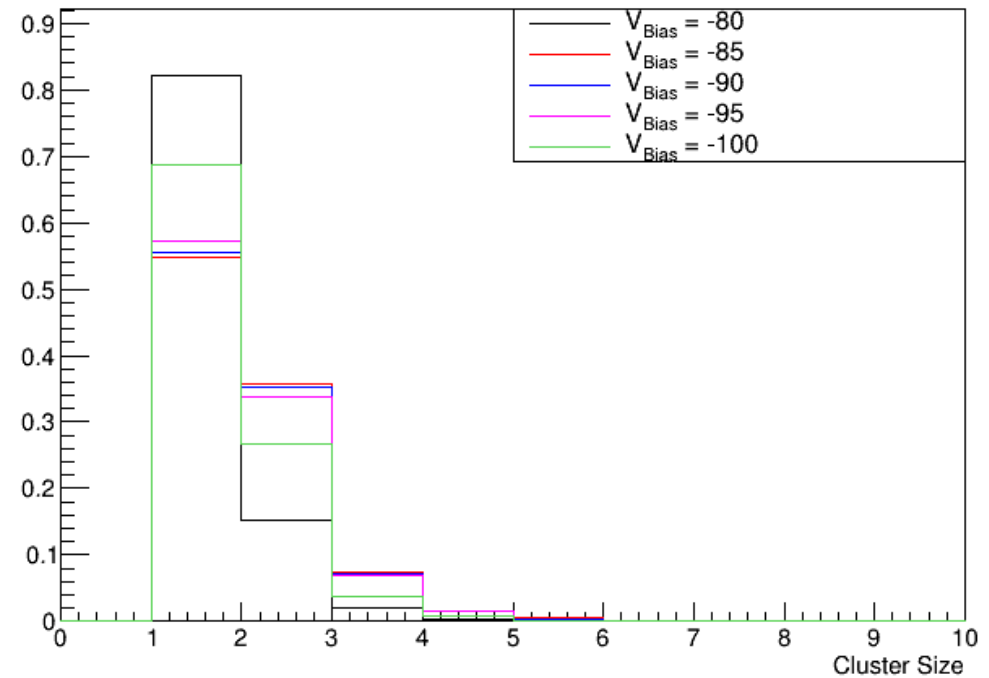
At $V_{\text{bias}} < V_{\text{bd}}$ the a region of connected pixel become extremely **noisy**
w/ **occupancy higher than 100%**

Cluster analysis

Cluster TOT at room Temperature



Cluster Size



- The cluster appear at $V_{bias} < -80V$
- The device is tuned at threshold = $3200e^-$ and $TOT = 30@20ke^-$
- We see less charge, maybe because of disconnected pixels.
- The foreseen charge amplification is not showing off within the breakdown

Conclusions

- **100 V are not enough** to ignite the charge multiplication
 - At least on this defectively bonded device
- **More tests** on LGAD devices are mandatory
- Today we bump bonded a new LGAD device from **6827-W14** run
 - 300 μm thick FEI3 w/ **deep diffusion** of dopant